## TOWARDS A MECHANISM FOR FORMATION OF SILICON CARBIDE CRYSTALS IN AGB STARS

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Silicon carbide (SiC) grains comprise a significant fraction of the dust found around carbon-rich AGB stars. Their presence in the interstellar medium is thought to originate from self-assembly of organosilicon building blocks, including previously observed species such as carborundum and cyclic silicon dicarbide (c-SiC<sub>2</sub>). However, the actual formation mechanisms of even these simple silicon-bearing organic molecules remains elusive. Here it is proposed that disilyne (Si<sub>2</sub>H<sub>2</sub>) reacts barrierlessly with abundant acetylene (C<sub>2</sub>H<sub>2</sub>) on a spin-conserving potential to form C<sub>2</sub>Si<sub>2</sub>H<sub>4</sub>. This species has been shown in experimental and theoretical studies<sup>*a*</sup> to photoisomerize under UV irradiation resulting in the formation of several species, one being a c-SiC<sub>2</sub> precursor and another being a highly polar species capable of supporting a dipole-bound electron. This strongly dipolar C<sub>2</sub>Si<sub>2</sub>H<sub>4</sub> isomer may represent the missing link supporting the molecular aggregation hypothesis for SiC formation. Importantly, its polarity drives molecular aggregation, and, after subsequent oxidation to C<sub>2</sub>Si<sub>2</sub>, its heteronuclear linkages are well-prepared for SiC nucleation, presumably initiated by a shock-wave pulsation event. Past theoretical studies by our group<sup>*bc*</sup> are combined with new results, computed at the DFT and coupled-cluster levels of theory, to support the proposed mechanism.

<sup>&</sup>lt;sup>a</sup>Lutz J.J., Inorganics, submitted

<sup>&</sup>lt;sup>b</sup>Lutz J.J., Duan X.F., et al. J. Chem. Phys. 148, 174309 (2018)

<sup>&</sup>lt;sup>c</sup>Byrd J.N., Lutz J.J., et al. J. Chem. Phys. 145, 024312 (2016)